Amendments to the Claims:

Please cancel claims 8-40.

This listing of claims will replace all prior versions, and listings, of the claims in the application:

Listing of Claims:

- 1. (Original) In the fabrication of a three dimensional memory where memory cells are formed at the intersection of generally parallel, spaced-apart rail-stacks disposed at a plurality of rail-stack levels, an improvement wherein the depth of etching in at least two etching steps used to form the rail-stacks in two adjacent rail-stack levels is approximately equal.
- 2. (Original) The improvement defined by claim 1, wherein each of the two etching steps etches a plurality of layers used to form the rail-stacks at one level of rail-stacks, and additionally partially etches rail-stacks in an underlying adjacent level of rail-stacks so as to form pillar structures in the underlying adjacent level of rail-stacks.
- 3. (Original) The improvement defined by claim 2, wherein the pillar structures comprise N- regions of silicon.
- 4. (Original) The improvement defined by claim 3, wherein the N- regions associated with diodes in the memory cells.
- 5. (Original) The improvement defined by claim 4, wherein the memory cells include an antifuse regions.

- 6. (Original) The improvement defined by claim 2, wherein the pillar structures are associated with diodes in the memory cells.
- 7. (Original) The improvement defined by claim 6, wherein the memory cells include antifuse regions.

8-40 (Canceled)